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| Form PTO-1449<br><b>INFORMATION DISCLOSURE CITATION<br/>IN AN APPLICATION</b><br><i>(Use several sheets if necessary)</i> | Docket Number 381092000700             | Application Number 09/030,482 |
|   | Applicant<br>Terrance P. SNUTCH et al. |                               |
|   | Filing Date February 25, 1998          | Group Art Unit 1646           |
|   | Mailing Date March <u>18</u> , 2003    |                               |

## U.S. PATENT DOCUMENTS

| Examiner<br>Initials | Ref.<br>No. | Date    | Document No. | Name            | Class | Subclass | Filing Date If<br>Appropriate |
|----------------------|-------------|---------|--------------|-----------------|-------|----------|-------------------------------|
| NSB                  | 1.          | 03/2003 | 6,528,630    | Williams et al. | 536   | 23.1     |                               |

## FOREIGN PATENT DOCUMENTS

| Examiner<br>Initials | Ref.<br>No. | Date | Document No. | Country | Class | Subclass | Translation<br>YES NO |
|----------------------|-------------|------|--------------|---------|-------|----------|-----------------------|
|                      |             |      |              |         |       |          |                       |

## OTHER DOCUMENTS

*(including author, title, Date, Pertinent Pages, Etc.)*

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| EXAMINER: <u>Ni/mel SB an</u> | DATE CONSIDERED: <u>7/11/03</u> |
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EXAMINER: Initial if citation considered, whether or not the citation conforms with MPEP 609. Draw a line through the citation if not in conformance and not considered. Include a copy of this form with next communication to applicant.